

Abstract

The present invention relates to an ultraviolet-curable resin composition characterized by containing (A) a (meth)acrylate having an aliphatic chain, particularly a C10 to 25 aliphatic chain, (B) a (meth)acrylate monomer other than the above-described (A) and the later-described (C), and/or (C) a urethane (meth)acrylate, and (D) a photopolymerization initiator, it is suitable for an intermediate resin layer particularly in a multilayer optical disk and excellent in mass production of substrate formation by the 2P method, and it has a particularly good detachability from a stamper, whereby it can provide a substrate for an optical disk having less warp variation when curing and after leaving a multilayer disk under high temperature and high humidity.